

Application/Control No.	Applicant(s)/Patent under Reexamination VANDENAMEELE-LEPLA, PATRICK	
10/042,780		
Examiner	Art Unit	
Linda Wong	2611	

SEARCHED					
Class	Subclass	Date	Examiner		
			7 - March 17 may 1		
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INTERFERENCE SEARCHED					
Class	Subclass	Date	Examiner		
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SEARCH NOTES (INCLUDING SEARCH STRATEGY)				
	DATE	EXMR		
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Scirus.com	8/31/2006	LW		
Interference Search	8/31/2006	LW		
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